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## Correction to "Topochemical Preparation of WO<sub>3</sub> Nanoplates through Precursor H<sub>2</sub>WO<sub>4</sub> and Their Gas-Sensing Performances"

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There was a mistake in the page range of reference 40 in the original manuscript. The corrected reference 40 is:

(40) Ou, J. Z.; Yaacob, M. H.; Breedon, M.; Zheng, H. D.; Campbell, J. L.; Latham, K.; du. Plessis, J.; Wlodarski, W.; Kalantar-zadeh, K. *Phys. Chem. Chem. Phys.* **2011**, *13*, 7330—7339.



Published: November 28, 2011